Internal-Mount End Block MC-Swing

For mounting inside a vacuum chamber, the new MC Swing Cathode[™] accommodates larger substrates and can replace planar cathodes without modifying the chamber.

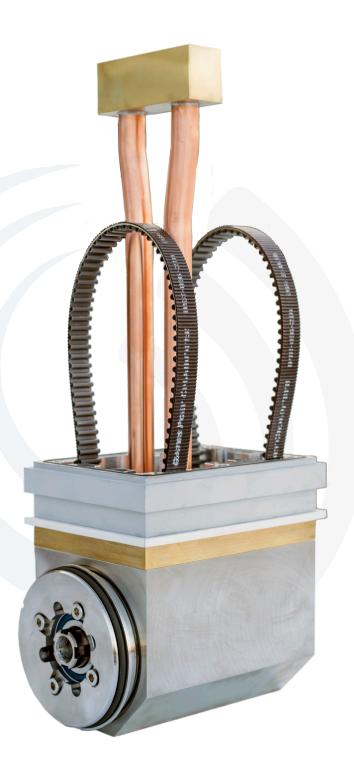
The magnet pack swings in a programmable rotary axis that is independent of the rotating target tube, making it an ideal system for display or 3D part coating.

Uniformity of $< \pm 1\%$ can be achieved on a static substrate (compared to $> \pm 15\%$ on static substrates when not using swing).

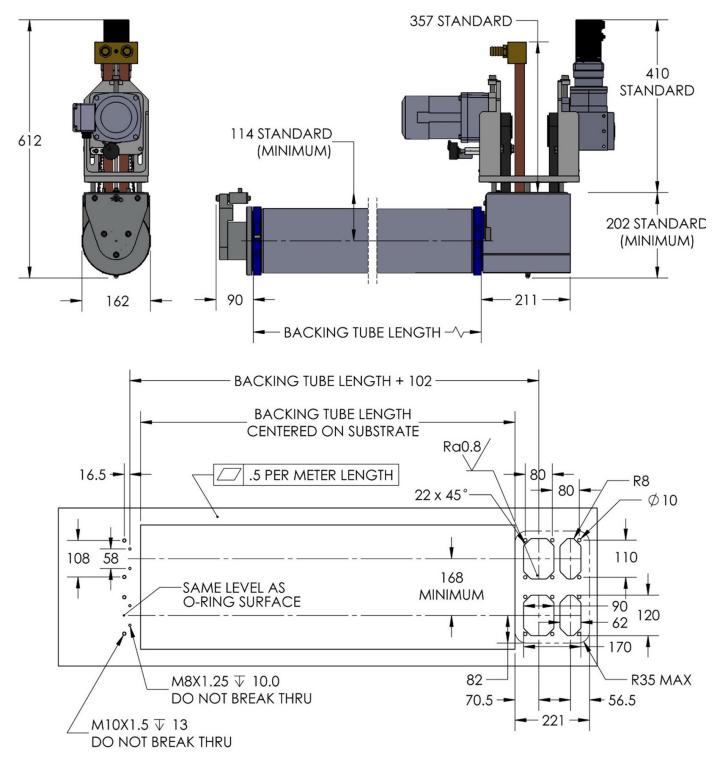
Other uses for Swing Cathodes[™] are to pivot the magnet bar to a burn in location or to make magnet bar position adjustments via remote control.

Our Swing Duo[™] software helps determine motion profiles.









Dimensions in mm

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